

| | L # | Hits | Search Text |
|----|-----|--------|---|
| 1 | L1 | 4 | 944145.ap. |
| 2 | L2 | 41299 | (mask or reticle) and (lithography or photolithography or photo-lithography) |
| 3 | L3 | 16290 | (substrate or wafer) same (focus or focal) |
| 4 | L4 | 209937 | ((projection near optical) or (lens or optical)) same (adjust\$4 or move or moving or moved or rotat\$3 or translat\$3 or manipul\$3) |
| 5 | L5 | 24068 | (correct\$3 or adjust\$4 or compensat\$3) with (focus or (focal near2 plane)) |
| 6 | L6 | 794 | 2 and 3 and 4 and 5 |
| 7 | L7 | 615 | 6 and (355/\$.ccls. or 430/\$.ccls. or 356/\$.ccls. or 250/\$.ccls.) |
| 8 | L8 | 2144 | (substrate or wafer) same (plane near2 focal) |
| 9 | L9 | 177 | 2 and 8 and 4 and 5 |
| 10 | L10 | 142 | 9 and (355/\$.ccls. or 430/\$.ccls. or 356/\$.ccls. or 250/\$.ccls.) |
| 11 | L11 | 123 | 9 and (355/\$.ccls. or 430/\$.ccls. or 356/\$.ccls.) |

2 km
6/27/03

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|----|-----|--------|---|
| 12 | L12 | 145316 | ((projection near optical) or (lens or optical)) with (adjust\$4 or move or moving or moved or rotat\$3 or translat\$3 or manipul\$3) |
| 13 | L13 | 14149 | (correct\$3 or adjust\$4 or compensat\$3) with (focus or (focal near2 plane)) with ((projection near optical) or (optical or lens)) |
| 14 | L14 | 13177 | 12 and 13 |
| 15 | L15 | 498 | 2 and 3 and 14 |
| 16 | L16 | 290 | 15 and (355/\$.ccls. or 430/\$.ccls. or 356/\$.ccls.) |
| 17 | L17 | 2878 | (chang\$3 or adjust\$4 or correct\$3) with (focal near plane) |
| 18 | L18 | 66 | 11 and 17 |
| 19 | L19 | 71 | (map\$4) with height with (wafer or substrate) |
| 20 | L20 | 680 | (stor\$3 or memor\$6 or map\$4) with (height or (surface near contour)) with (wafer or substrate) |
| 21 | L21 | 168 | 20 and 2 |
| 22 | L22 | 30 | 21 and (355/\$.ccls. or 430/\$.ccls. or 356/\$.ccls.) |

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|----|-----|-------|---|
| 23 | L23 | 24068 | (correct\$3 or adjust\$4 or compensat\$3) with (focus or (focal near2 plane)) |
| 24 | L24 | 18 | 22 and 23 |